Atty. Docket No. 30205/39714 Inventors: Geun Su Lee et al.

Title:. "Cleaning Solution for Photoresist and Method for

Forming Pattern Using the Same"

Sheet 1 of 3

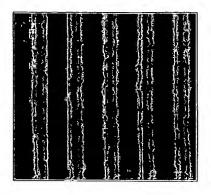


Fig.1

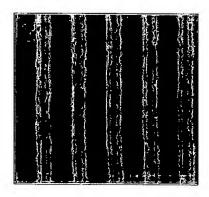


Fig.2

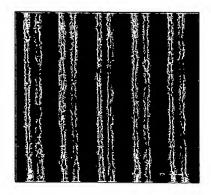


Fig.3

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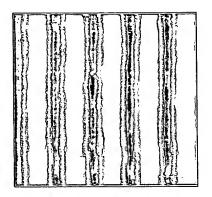


Fig.4

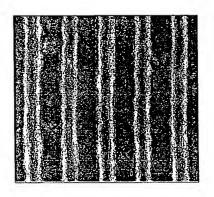


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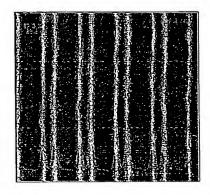


Fig.6

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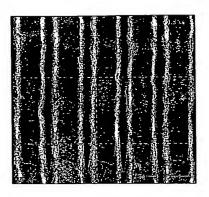


Fig.7

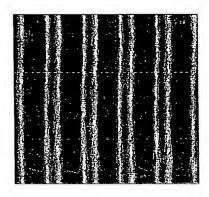


Fig.8

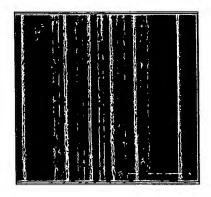


Fig.9